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Addressing Gaps between Textiles and Apparel Curriculum and the Industry in Kenya

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The textiles & apparel (T&A) industry holds the highest potential for not only fostering Africa's export competitiveness and economic development but creating substantial employment opportunities (Tuigong & Kipkurgat, 2015). Among East African countries, Kenya and Ethiopia have the potential to become bigger players in garment manufacturing (Berg, Hedrich, & Russo, 2015). In particular, Kenya's T&A industry has earned its reputation in the global market as one of the leading emerging garment suppliers for high volumes of bulk basics. Kenya's vision for 2030 prioritizes the T&A manufacturing sector as a catalyst for the country's economic development with a projected 10 percent growth rate annually (African Cotton & Textile Industries Federation, 2010). In addition, the renewal of the African Growth and Opportunity Act (AGOA) in 2015 placed a heavy emphasis on Africa's emerging T&A industry and generated high interests among U.S. firms to source apparel from Kenya and other East African countries. AGOA has contributed to the rapid growth of Kenya's T&A exports to the U.S. and the T&A industry continues to be a highly dynamic and important sector of the Kenyan economy. However, increasing globalization brought new challenges for the Kenyan T&A industry with cheaper imports from the East and second-hand clothing from the west, while the development of skilled labor and new talents has been stalled. Despite emerging career opportunities for college graduates with a T&A major in Kenya, Nguku (2012) argues that current T&A curriculum at universities in Kenya lacks a direct practical link to the fast emerging T&A industries and has critical gaps to meet the emerging needs of the T&A industry in Kenya.

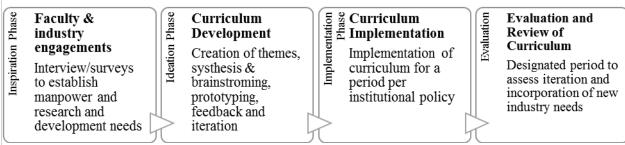
To help address gaps between the T&A curriculum and emerging industry needs in Kenya, we propose collaborative research among T&A educators from Kenya and U.S. with diverse academic and industry backgrounds. Based on preliminary interviews with Kenyan educators and relevant literature reviews, we developed the following research questions; (1) what are the current and emerging needs of T&A industries in Kenya (2) how has university curriculum accommodated these needs (3) what are the program-level goals and outcomes from the current T&A curriculum and (4) what are the critical gaps between industry needs and curriculum. To address the research questions, Human-Centered Design (HCD) will guide the research process (www.designkit.org, n.d.). HCD is an ideal approach to develop an innovative T&A curriculum that addresses both the specific needs of Kenyan's T&A industry and graduates in Kenya. We will follow the three main phases of HCD: (a) *Inspiration*, (b) *Ideation*, and (c) *Implementation*. During the *Inspiration* phase, we will engage in empathetic inquiry to identify

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© 2017, International Textile and Apparel Association, Inc. ALL RIGHTS RESERVED ITAA Proceedings, #74 - www.itaaonline.org gaps between the T&A curriculum and industry in Kenya. For empathetic inquiry, we will first conduct a content analysis of current T&A curriculum. To gain deeper insights about curriculum gaps and emerging challenges, we will further conduct interviews and survey with three primary constituencies (faculty, students/recent graduates, and employers). Our goal is to gain insights about both internal (e.g., students) and external environments (e.g., technology, trade environment) pertinent to the T&A education and industry in Kenya.

During the *Ideation* phase, we will work primarily with T&A educators in Kenya to brainstorm innovative T&A curriculums based on learning from the earlier phase and build curriculum prototypes to test. We will then gather feedback on curriculum prototypes from T&A educators and employers and go through multiple iterations to refine prototypes. During the *Implementation* phase, we will work with T&A educators to develop a plan to implement the refined T&A curriculum into their universities. See Figure 1 for the HCD process.

Figure 1: Framework adapted from the HCD



In order to fully realize potential benefits of the T&A industry and place Kenya in a competitive in a global marketplace, there is a pressing need to address existing gaps between the curriculum and emerging T&A industry in Kenya through collaboration with stakeholders. This study proposes collaborations among educators in the T&A programs between Kenya and U.S. to leverage the potentials of the Kenyan T&A industry. This proposed collaboration following the HCD process can be a practical example for other countries that have not yet fully realized the potentials of T&A industry for their economic and social benefits. References:

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